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<p>Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number.</p> <p>Substitute for form 1449/PTO</p> <p>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</p> <p><i>(Use as many sheets as necessary)</i></p>				<p>Complete if Known</p> <p>Application Number 10/756,122-Conf. #4554</p> <p>Filing Date January 13, 2004</p> <p>First Named Inventor Wai-Fan Yau</p> <p>Art Unit 2823</p> <p>Examiner Name J. J. Maldonado</p> <p>Attorney Docket Number 002592.C7/DSM/LOW K/JW</p>	
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U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

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Examiner Signature	/Julio Maldonado/	Date Considered	07/21/2009
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***EXAMINER:** Initial if reference concise, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not amended. Include copy of this form with next communication to applicant. * CITE NO.: Those application(s) which are marked with an single asterisk (*) next to the Cite No. are not supplied (under 37 CFR 1.98(a)(2)(ii)) because that publication was filed after June 30, 2003 or is available in the IFW. * Applicant's unique citation designation number (optional). See USPTO Patent Documents at www.uspto.gov or MPEP 901.04. * Enter Office that issued the patent document (e.g., "USPTO," "ESTR," "ST-3"). * Indicate the year of the grant of the patent document by entering the year of the grant of the patent document preceding the serial number of the patent document. * Indicate the language by the appropriate symbol as indicated in the document under WIPO Standard ST.16 is possible. * Applicant is to place a check mark here if English language transcription is attached.

Substitute for form 1449/PTO <h2 style="text-align: center;">INFORMATION DISCLOSURE STATEMENT BY APPLICANT</h2> <p style="text-align: center;">(Use as many sheets as necessary)</p>		Complete if Known <table border="1" style="width: 100%; border-collapse: collapse;"> <tr> <td style="width: 30%;">Application Number</td> <td>10/756,122-Conf. #4554</td> </tr> <tr> <td>Filing Date</td> <td>January 13, 2004</td> </tr> <tr> <td>First Named Inventor</td> <td>Wai-Fan Yau</td> </tr> <tr> <td>Art Unit</td> <td>2823</td> </tr> <tr> <td>Examiner Name</td> <td>J. J. Maldonado</td> </tr> <tr> <td>Attorney Docket Number</td> <td>002592.C7/DSM/LOW K/JW</td> </tr> </table>		Application Number	10/756,122-Conf. #4554	Filing Date	January 13, 2004	First Named Inventor	Wai-Fan Yau	Art Unit	2823	Examiner Name	J. J. Maldonado	Attorney Docket Number	002592.C7/DSM/LOW K/JW
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NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
/J.M./	C1	K.H.A. BOGART, ET AL., "Plasma Enhanced Chemical Vapor Deposition of SiO ₂ Using Novel Alkoxysilane Precursors," J. Vac. Sci. Technol. A, Vol. 13, No. 2, Mar/Apr 1995, pages 475-480.	
	C2	A. KLUMP, "Photo Induced Transformation of Polysiloxane Layers to SiO ₂ ," Applied Surface Science, Volume 43 (1989), pages 301-303.	
	C3	The Board's Decision on Appeal mailed September 16, 2004, for Serial No. 09/477,126, filed December 30, 1999 (AMAT/2592.X1).	
	C4	The Board's Decision on Request for Rehearing mailed December 23, 2004, for Serial No. 09/477,126, filed December 30, 1999 (AMAT/2592.X1).	
	C5	WOLF, et al.; Silicon Processing for the VLSI Era, Volume 1; Process Technology, 1986 by Lattice Press, pp. 161-174.	
/J.M./	C6	Prosecution History for U.S. Patent Application No. 11/877,483 filed October 23, 2007 (APPM/002592.C12)	

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